



# JD/LLM in Intellectual Property and Technology Law Program

The **Master of Laws (LLM) in Intellectual Property and Technology**

**Law** responds to the demand for knowledgeable and skilled intellectual property professionals who are also earning the Juris Doctor degree. The program's curriculum allows students to study introductory and advanced intellectual property law and to scrutinize the politics affecting those areas of the law under the guidance of leading scholars in the field. Students participate in practical skills courses taught in small groups by teams of experienced intellectual property lawyers.

Students earn both a Juris Doctor (JD) and an LLM in Intellectual Property and Technology Law in either the six-semester program or the seven-semester program. The innovative and unique six-semester program allows students to earn both degrees without sacrificing summer employment opportunities, thereby giving students a competitive advantage in the employment market at graduation.

The joint-degree program requires a total of 94 credits for graduation with both degrees, as compared with the 86 credits required for the JD degree. Students must take at least 15 credits of courses from the Intellectual Property and Technology Law curriculum.

Students taking the combined degree program are required to pay an extra semester's tuition at a 40% discount, which is payable during the student's final semester.